|   | Application No.   | Applicant(s)   |  |
|---|---|--|--|
| Notice of Allowability  | 10/550,411  | NUNES VICENTE REBORDAO ET AL.  |  |
|   | Examiner  | Art Unit   |  |
|   | Leo Boutsikaris   | 2872   |  |
| The MAILING DATE of this communication app All claims being allowable, PROSECUTION ON THE MERITS IS herewith (or previously mailed), a Notice of Allowance (PTOL-85 NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT F of the Office or upon petition by the applicant. See 37 CFR 1.31  | S (OR REMAINS) CLOSED in this ap<br>S) or other appropriate communication<br>RIGHTS. This application is subject to   | plication. If not included not will be mailed in due course. THIS  |  |
| 1. $\boxtimes$ This communication is responsive to <u>amendment filed on</u>  | <u>6/25/07</u> .  |  |  |
| 2. The allowed claim(s) is/are 1.7-10.  |   |  |  |
| 3. Acknowledgment is made of a claim for foreign priority of a) All b) Some* c) None of the:  1. Certified copies of the priority documents have 2. Certified copies of the priority documents have 3. Copies of the certified copies of the priority documents have International Bureau (PCT Rule 17.2(a)).  * Certified copies not received:  Applicant has THREE MONTHS FROM THE "MAILING DATE" noted below. Failure to timely comply will result in ABANDONITHIS THREE-MONTH PERIOD IS NOT EXTENDABLE.  4. A SUBSTITUTE OATH OR DECLARATION must be subminified including changes required by the Notice of Draftsper 1) hereto or 2) to Paper No./Mail Date  (b) including changes required by the attached Examiner Paper No./Mail Date  Identifying Indicia such as the application number (see 37 CFR each sheet. Replacement sheets) should be labeled as such in | ve been received. ve been received in Application No ocuments have been received in this " of this communication to file a reply MENT of this application.  mitted. Note the attached EXAMINER ves reason(s) why the oath or declara- ust be submitted. rson's Patent Drawing Review ( PTO r's Amendment / Comment or in the C  1.84(c)) should be written on the drawing | national stage application from the complying with the requirements  'S AMENDMENT or NOTICE OF ation is deficient.  948) attached  Office action of the back) of |  |
| 6. DEPOSIT OF and/or INFORMATION about the deposit attached Examiner's comment regarding REQUIREMENT  |   |  |  |
| Attachment(s)  1. Notice of References Cited (PTO-892)  | 5. ☐ Notice of Informal F   | atent Application  |  |
| 2.  Notice of Draftperson's Patent Drawing Review (PTO-948)   |   |  |  |
| 3. Information Disclosure Statements (PTO/SB/08), Paper No./Mail Date   | Paper No./Mail Da<br>7. ⊠ Examiner's Amendr   |  |  |
| 4. Examiner's Comment Regarding Requirement for Deposit of Biological Material  | 8. 🛛 Examiner's Stateme   | ent of Reasons for Allowance   |  |
| of biological Material  | 9.  | LEONIDAS BOUTSIKARIS PRIMARY EXAMINER  |  |
|   |   | Leo Boutsikaris, Ph.D., Esq. Primary Patent Examiner, AU 2872  |  |

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**EXAMINER'S AMENDMENT** 

An examiner's amendment to the record appears below. Should the changes and/or

additions be unacceptable to applicant, an amendment may be filed as provided by 37 CFR

1.312. To ensure consideration of such an amendment, it MUST be submitted no later than the

payment of the issue fee.

Authorization for this examiner's amendment was given in a telephone interview with

Mr. Caleb Pollack (Reg. No. 37,912) on 8/20/2007.

The application has been amended as follows:

IN THE CLAIMS

Claim 1 is rewritten as follows:

1. A maskless optical device based on interferometric lithography to generate an

interference pattern[s] within selected areas of a photosensitive material ensuring that the

surrounding area is not affected by light, producing diffractive optical variable image devices for

security, [the device] comprising:

a first optical channel and a second optical channel at an angle for interfering with the

photosensitive material; the first optical channel comprising a first imaging lens for producing an

image from a first object at an image plane; the second optical channel comprising a second

imaging lens for producing an image from a second object at the image plane, and wherein the

device complies with the Scheimpflug rule and the Hinge rule; wherein the interference pattern

comprises the images of the first and second objects;

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[an in plane holography imaging device comprising an arbitrary number of objects, the images of which when combined, are for building up a final interference pattern; an optical device based on the Scheimpflug and Hinge rules for ensuring adequate superposition between different optical beams in an imaging configuration; and two optical channels for interfering in the photosensitive material with an adequate angle;]

wherein the time needed to register a complete polygonal pattern is linearly proportional to the number of [colors] <u>interference patterns</u> specified for the reference geometry and not to the overall area of the optical device.

Claim 8 is rewritten as follows:

8. The maskless optical device of claim 1 wherein the photosensitive material [can be] is rotated to materiali[s]ze diffractive patterns with different grating orientation.

Claim 9 is rewritten as follows:

9. The maskless optical device of claim 1 wherein the angle between the optical channels is controllable to materiali[s]ze diffractive patterns with different grating orientation.

The following is an examiner's statement of reasons for allowance:

Claims 1, 7-10 are allowable over the prior art of record for at least the reason that even though the prior art discloses holographic lithographic systems, which do not utilize a mask in the proximity of the recording area, the prior art fails to teach or reasonably suggest a maskless optical device based on interferometric lithography, wherein the device complies with the Scheimpflug rule and the Hinge rule, as set forth by the claimed combination.

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The above rules are related to a specific relative orientation of the object, image and lens planes in the holographic recording geometry, and ensure the correct superposition of the projected images at the recording area without the need of a blocking mask.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

## Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Dr. Leo Boutsikaris whose telephone number is 571-272-2308. The examiner can normally be reached on M-F, 10-6.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Stephone Allen can be reached on 571-272-2434. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free). If you would

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like assistance from a USPTO Customer Service Representative or access to the automated information system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.

Leo Boutsikaris, Ph.D., Esq.

Primary Patent Examiner, AU 2872

August 20, 2007

LEONIDAS BOUTSIKARIS
PRIMARY EXAMINER